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Sheet 1

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Art Unit 28/3

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U. S. PATENT DOCUMENTS Examine Document Number Publication Date Name of Patentee or Pages, Columns, Lines, Where Initials* No.1 MM-DD-YYYY Applicant of Cited Document Relevant Passages or Relevant Number-Kind Code² (# known) Figures Appear ^{US-} 6,229,161 5-8-2001 Nemati et al. US- 6.104,045 8-15-2000 Forbes et al. US-4,797,373 1-10-1989 Malhi et al. ^{US-} 6,225,165 5-1-2001 Noble, Jr. et al. US- 5,528,062 6-18-1996 Hsieh et al. 7-1992 ^{US-} 5,132,767 Ogura et al. US-6,084,274 7-2000 Mukai et al. US- 5,600,160 2-1997 Hvistendahl US-6,545,297 4-2003 Nobel, Jr. et al. US-6,583,452 6-2003 Cho et al. US- 4,395,723 Harari 7-1983 US-2002/0190265 A1 12-2002 Hsu et al. US-US-US-US-US-ŪŠ-

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Examiner Initials*	Cite No.1	Foreign Patent Document	Publication Date	Name of Patentee or Applicant of Cited Document			
		Country Code ³ "Number ⁴ "Kind Code ³ (if known)	MM-DD-YYYY		Or Relevant Figures Appear	T°	
WOV		Japan 3-16089	1-1991	Sato et al.			
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STATEMENT BY APPLICANT					First Named Inventor	Farid Nen	nati		
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Attorney Docket Number

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